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Docket No.: 2336-265

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Inventor(s): Suk Kee HONG et al.

U.S. Patent Application No. 10/822,726

Filed: April 13, 2004

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: Confirmation No. 2906
:
: Group Art Unit: 2874
:
: Examiner:

For: WAVELENGTH DIVISION MULTIPLEXING SYSTEM HAVING BUILT-IN
OPTICAL ATTENUATOR

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

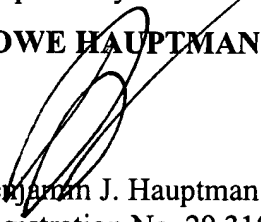
Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.


This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

Respectfully submitted,

LOWE HAUPTMAN & BERNER, LLP


Benjamin J. Hauptman
Registration No. 29,310

1700 Diagonal Road, Suite 300
Alexandria, Virginia 22314
(703) 684-1111 BJH/jk
Facsimile: (703) 518-5499
Date: August 24, 2005

INFORMATION DISCLOSURE CITATION IN AN APPLICATION				ATTY. DOCKET NO. 2336-265		U.S. PATENT APPLICATION NO. 10/822,726	
				APPLICANT Suk Kee HONG et al.			
				FILING DATE April 13, 2004		GROUP 2874	
				U.S. PATENT DOCUMENTS			
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
FOREIGN PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No
	2001-0113591A	12/2001	Korea			X	
	2001-194597	7/2001	Japan			X	
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
EXAMINER				DATE CONSIDERED			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.